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LIST OF PUBLICATIONS AND PATENTS

1. List of publications

a. Journal publications

1. P. Argitis, and E. Papaconstantinou, "Photocatalytic Multielectron Photoreduction of 18-Tungstodiphosphate in the Presence of Organic Compounds - Production of Hydrogen", **J. Photochem.**, **30**, 445-451, 1985.
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